

<u>NEWS 1</u>	Web Page URLs for STN Seminar Schedule - N. America	
<u>NEWS 2</u>	"Ask CAS" for self-help around the clock	
<u>NEWS 3</u>	Feb 24	PCTGEN now available on STN
<u>NEWS 4</u>	Feb 24	TEMA now available on STN
<u>NEWS 5</u>	Feb 26	NTIS now allows simultaneous left and right truncation
<u>NEWS 6</u>	Feb 26	PCTFULL now contains images
<u>NEWS 7</u>	Mar 04	SDI PACKAGE for monthly delivery of multifile SDI results
<u>NEWS 8</u>	Mar 24	PATDPAFULL now available on STN
<u>NEWS 9</u>	Mar 24	Additional information for trade-named substances without structures available in REGISTRY
<u>NEWS 10</u>	Apr 11	Display formats in DGENE enhanced
<u>NEWS 11</u>	Apr 14	MEDLINE Reload
<u>NEWS 12</u>	Apr 17	Polymer searching in REGISTRY enhanced
<u>NEWS 13</u>	Jun 13	Indexing from 1947 to 1956 added to records in CA/CAPLUS
<u>NEWS 14</u>	Apr 21	New current-awareness alert (SDI) frequency in WPIDS/WPINDEX/WPIX
<u>NEWS 15</u>	Apr 28	RDISCLOSURE now available on STN
<u>NEWS 16</u>	May 05	Pharmacokinetic information and systematic chemical names added to PHAR
<u>NEWS 17</u>	May 15	MEDLINE file segment of TOXCENTER reloaded
<u>NEWS 18</u>	May 15	Supporter information for ENCOMPPAT and ENCOMPLIT updated
<u>NEWS 19</u>	May 19	Simultaneous left and right truncation added to WSCA
<u>NEWS 20</u>	May 19	RAPRA enhanced with new search field, simultaneous left and right truncation
<u>NEWS 21</u>	Jun 06	Simultaneous left and right truncation added to CBNB
<u>NEWS 22</u>	Jun 06	PASCAL enhanced with additional data
<u>NEWS 23</u>	Jun 20	2003 edition of the FSTA Thesaurus is now available
<u>NEWS 24</u>	Jun 25	HSDB has been reloaded
<u>NEWS 25</u>	Jul 16	Data from 1960-1976 added to RDISCLOSURE
<u>NEWS 26</u>	Jul 21	Identification of STN records implemented
<u>NEWS 27</u>	Jul 21	Polymer class term count added to REGISTRY
<u>NEWS 28</u>	Jul 22	INPADOC: Basic index (/BI) enhanced; Simultaneous Left and Right Truncation available

NEWS EXPRESS April 4 CURRENT WINDOWS VERSION IS V6.01a, CURRENT MACINTOSH VERSION IS V6.0b(ENG) AND V6.0Jb(JP),

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FILE 'HOME' ENTERED AT 14:14:16 ON 05 AUG 2003

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FILE 'EUROPATFULL' ENTERED AT 14:14:42 ON 05 AUG 2003  
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FILE 'PATDPAFULL' ENTERED AT 14:14:42 ON 05 AUG 2003  
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FILE 'USPATFULL' ENTERED AT 14:14:42 ON 05 AUG 2003  
 CA INDEXING COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

FILE 'USPAT2' ENTERED AT 14:14:42 ON 05 AUG 2003  
 CA INDEXING COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

=> s Blomquist, Robert/in  
 'IN' IS NOT A VALID FIELD CODE  
 L1 18 BLOMQUIST, ROBERT/IN

=> s l1 and energy curable  
 L2 1 L1 AND ENERGY CURABLE

=> d

L2 ANSWER 1 OF 1 PCTFULL COPYRIGHT 2003 Univentio on STN

Full  
 Text

AN 2003011915 PCTFULL ED 20030228 EW 200307  
 TIEN FLUORINATED OPTICAL POLYMER COMPOSITION  
 TIFR COMPOSITION POLYMER OPTIQUE FLUOREE  
 IN BLOMQUIST, Robert, 30 Birch Hill Drive, Whippany, NJ 07981, US  
 PA CORNING INCORPORATED, 1 Riverfront Plaza, Corning, NY 14831, US [US, US]  
 AG SUGGS, James, V, CORNING INCORPORATED, Patent Department, SP TI 3-1,  
 Corning, NY 14831, US  
 LAF English  
 LA English  
 DT Patent  
 PI WO 2003011915 A1 20030213  
 DS W: AE AG AL AM AT AU AZ BA BB BG BR BY BZ CA CH CN CO CR CU CZ  
 DE DK DM DZ EC EE ES FI GB GD GE GH GM HR HU ID IL IN IS JP  
 KE KG KP KR KZ LC LK LS LT LU LV MA MD MG MK MN MW MX MZ  
 NO NZ OM PH PL PT RO RU SD SE SG SI SK SL TJ TM TN TR TT TZ  
 UA UG UZ VN YU ZA ZM ZW  
 RW (EPO): AT BE CH CY DE DK ES FI FR GB GR IE IT LU MC NL PT SE TR  
 AI WO 2002-US13673 A 20020429  
 PRAI US 2001-09/912,827 20010725  
 ICM C08F002-46  
 ICS G03C001-73; G03C001-725; G03C005-00; G02B006-10

=> s energy curable, (aromatic or heteroaromatic moiety), fluorinat?, ethylenically u  
 MISSING OPERATOR 'CURABLE, (AROMATIC'  
 The search profile that was entered contains terms or  
 nested terms that are not separated by a logical operator.

=> s energy curable and (aromatic or heteroaromatic moiety)  
 L3 263 ENERGY CURABLE AND (AROMATIC OR HETEROAROMATIC MOIETY)

=> s l3 and fluorinat?  
 L4 52 L3 AND FLUORINAT?

=> s l4 and ethylenically unsaturated  
 L5 19 L4 AND ETHYLENICALLY UNSATURATED

```
=> s 15 and initiator#
L6           14 L5 AND INITIATOR#  

  

=> s 16 and isocyanurate moiety
L7           0 L6 AND ISOCYANURATE MOIETY  

  

=> s 16 and isocyanurate
L8           6 L6 AND ISOCYANURATE  

  

=> s 18 and compound#
L9           6 L8 AND COMPOUND#  

  

=> s 19 and (polymer# or copolymer#)
L10          6 L9 AND (POLYMER# OR COPOLYMER#)  

  

=> s 110 and optical element#
L11          0 L10 AND OPTICAL ELEMENT#
```

=> d 110 1-6

L10 ANSWER 1 OF 6 EUROPATFULL COPYRIGHT 2003 WILA on STN

Full  
 Text

GRANTED PATENT - ERTEILTES PATENT - BREVET DELIVRE

AN	1025176	EUROPATFULL ED 20020605 EW 200221 FS PS
TIEN	PROTECTIVE FILMS AND COATINGS.	
TIDE	SCHUTZSCHICHTEN UND BESCHICHTUNGEN.	
TIFR	FILMS ET REVETEMENTS PROTECTEURS.	
IN	BARRERA, Denise, A., P.O. Box 33427, Saint Paul, MN 55133-3427, US	
PA	MINNESOTA MINING AND MANUFACTURING COMPANY, 3M Center, P.O. Box 33427, St. Paul, Minnesota 55133-3427, US	
SO	Wila-EPS-2002-H21-T1	
DS	R DE; R FR; R GB; R IT; R SE	
PIT	EPB1 EUROPÄISCHE PATENTSCHRIFT (Internationale Anmeldung)	
PI	<u>EP 1025176</u>	B1 20020522
OD	20000809	
AI	<u>EP 1998-951044</u>	19981013
PRAI	<u>US 1997-949367</u>	19971014
RLI	<u>WO 98-US21514</u>	981013 INTAKZ
	<u>WO 9919414</u>	990422 INTPNR
REP	<u>US 4128600</u> A	<u>US 5009936</u> A
IC	ICM C09J007-02	
	ICS B32B027-08	

L10 ANSWER 2 OF 6 EUROPATFULL COPYRIGHT 2003 WILA on STN

Full  
 Text

PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET

AN	376655	EUROPATFULL ED 20000910 EW 199027 FS OS STA B
TIEN	Photographic element and preparation thereof.	
TIDE	Photographisches Element und dessen Herstellung.	
TIFR	Element photographique et sa preparation.	
IN	Kobayashi, Tohru Konica Corporation, 26-2 Nishi-shinjuku 1-chome Shinjuku-ku, Tokyo, JP;	
	Nishi, Yasuo Konica Corporation, 26-2 Nishi-shinjuku 1-chome Shinjuku-ku, Tokyo, JP;	
	Nakano, Nakaya Konica Corporation, 26-2 Nishi-shinjuku 1-chome Shinjuku-ku, Tokyo, JP;	
	Ohkawa, Kazuo c/o Asahi Denka Kogyo K.K., 2-35 Higashi-ogu 7-chome	

Arawaka-ku, Tokyo, JP;  
 Tachikawa, Hiroyuki c/o Asahi Denka Kogyo K.K., 2-35 Higashi-ogu 7-chome  
 Arawaka-ku, Tokyo, JP  
 PA KONICA CORPORATION, No. 26-2, Nishishinjuku 1-chome Shinjuku-ku, Tokyo,  
 JP;  
 ASAHI DENKA KOGYO KABUSHIKI KAISHA, 2-35, Higashiogu 7-chome, Arakawa-ku  
 Tokyo 116, JP  
 SO Wila-EPZ-1990-H27-T2  
 DS R DE; R GB; R NL  
 PIT EPA2 EUROPÄISCHE PATENTANMELDUNG  
PI EP 376655 A2 19900704  
OD 19900704  
AI EP 1989-313525 19891222  
PRAI JP 1988-335608 19881229  
IC ICM G03C011-08

## GRANTED PATENT - ERTEILTES PATENT - BREVET DELIVRE

AN 376655 EUROPATFULL UP 20010712 EW 199540 FS PS STA B  
 TIEN Photographic element and preparation thereof.  
 TIDE Photographisches Element und dessen Herstellung.  
 TIFR Element photographique et sa preparation.  
 IN Kobayashi, Tohru Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
 Shinjuku-ku, Tokyo, JP;  
 Nishi, Yasuo Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
 Shinjuku-ku, Tokyo, JP;  
 Nakano, Nakaya Konica Corporation, 26-2 Nishi-shinjuku 1-chome  
 Shinjuku-ku, Tokyo, JP;  
 Ohkawa, Kazuo c/o Asahi Denka Kogyo K.K., 2-35 Higashi-ogu 7-chome  
 Arawaka-ku, Tokyo, JP;  
 Tachikawa, Hiroyuki c/o Asahi Denka Kogyo K.K., 2-35 Higashi-ogu 7-chome  
 Arawaka-ku, Tokyo, JP  
 PA KONICA CORPORATION, 26-2, Nishishinjuku 1-chome, Shinjuku-ku, Tokyo 160,  
 JP;  
 ASAHI DENKA KOGYO KABUSHIKI KAISHA, 2-35, Higashiogu 7-chome, Arakawa-ku  
 Tokyo 116, JP  
 SO Wila-EPS-1995-H40-T2  
 DS R DE; R GB; R NL  
 PIT EPB1 EUROPÄISCHE PATENTSCHRIFT  
PI EP 376655 B1 19951004  
OD 19900704  
AI EP 1989-313525 19891222  
PRAI JP 1988-335608 19881229  
REP US 4426431 A  
 REN PATENT ABSTRACTS OF JAPAN, vol. 11, no. 201 (P-500) (2648) 30 June 1987 &  
 JP-A-62 021 150 Ronald S. Bauer (ED) 'Epoxy Resin Chemistry' 1981,  
 American Chemical Society, Washington US, Chapter 2, "Photosensitized  
 epoxides as basis for light-curable coatings", pp. 17-45  
 IC ICM G03C011-08

L10 ANSWER 3 OF 6 PCTFULL COPYRIGHT 2003 Univentio on STN

**Full**  
**Text**

AN 2002090412 PCTFULL ED 20021121 EW 200246  
 TIEN ENERGY CURABLE ADDUCT CONTAINING A FLUORO GROUP AND COATINGS THEREFROM  
 TIFR PRODUIT D'ADDITION POUVANT ETRE DURCI PAR DE L'ENERGIE, CONTENANT UN  
 GROUPE FLUORO, ET REVETEMENTS FABRIQUES A PARTIR DUDIT PRODUIT  
 IN BIRCH, Adrian, J., La Traviata, Slnt-Jansteen 4564ER, NL [GB, NL];  
 DUFF, Alan, W., Saxhavenstraat 10, Hulst 4561HC, NL [GB, NL];  
 BARTELINK, Camiel, F., Robijnboog 31, Terneuzen 4533BA, NL [NL, NL]  
 PA DOW GLOBAL TECHNOLOGIES INC., Washington Street, 1790 Building, Midland,  
 MI 48674, US [US, US], for all designates States except US;  
 BIRCH, Adrian, J., La Traviata, Slnt-Jansteen 4564ER, NL [GB, NL], for  
 US only;

DUFF, Alan, W., Saxhavenstraat 10, Hulst 4561HC, NL [GB, NL], for US only;  
 BARTELINK, Camiel, F., Robijnboog 31, Terneuzen 4533BA, NL [NL, NL], for US only  
 AG ULMER, Duane, C., The Dow Chemical Company, Intellectual Property,  
 B-1211, 2301 North Brazosport Boulevard, Freeport, TX 77541, US  
 LAF English  
 LA English  
 DT Patent  
 PI WO 2002090412 A1 20021114  
 DS W: AE AG AL AM AT AU AZ BA BB BG BR BY BZ CA CH CN CO CR CZ DE  
 DK DM DZ EC EE ES FI GB GD GE GH GM HR HU ID IL IN IS JP KE  
 KG KR KZ LC LK LS LT LU LV MA MD MG MK MN MW MX MZ NO NZ  
 OM PH PL PT RO RU SD SE SG SI SK SL TJ TM TN TR TT TZ UA UG  
 US UZ YU ZA ZM ZW  
 RW (ARIPO): GH GM KE LS MW MZ SD SL SZ TZ UG ZM ZW  
 RW (EAPO): AM AZ BY KG KZ MD RU TJ TM  
 RW (EPO): AT BE CH CY DE DK ES FI FR GB GR IE IT LU MC NL PT SE TR  
 RW (OAPI): BF BJ CF CG CI CM GA GN GQ GW ML MR NE SN TD TG  
 AI WO 2002-US14309 A 20020507  
 PRAI US 2001-60/289, 344 20010507  
 ICM C08G018-10  
 ICS C08G018-28; C08G018-67; C08G018-48; C08G018-75

L10 ANSWER 4 OF 6 PCTFULL COPYRIGHT 2003 Univentio on STN

Full  Text

AN 1999019414 PCTFULL ED 20020515  
 TIEN PROTECTIVE FILMS AND COATINGS  
 TIFR FILMS ET REVETEMENTS PROTECTEURS  
 IN BARRERA, Denise, A.  
 PA MINNESOTA MINING AND MANUFACTURING COMPANY  
 LA English  
 DT Patent  
 PI WO 9919414 A1 19990422  
 DS W: AL AM AT AU AZ BA BB BG BR BY CA CH CN CU CZ DE DK EE ES FI  
 GB GD GE GH GM HR HU ID IL IS JP KE KG KP KR KZ LC LK LS  
 LT LU LV MD MG MK MN MW MX NO NZ PL PT RO RU SD SE SG SI SK  
 SL TJ TM TR TT UA UG UZ VN YU ZW GH GM KE LS MW SD SZ UG ZW  
 AM AZ BY KG KZ MD RU TJ TM AT BE CH CY DE DK ES FI FR GB GR  
 IE IT LU MC NL PT SE BF BJ CF CG CI CM GA GN GW ML MR NE SN  
 TD TG  
 AI WO 1998-US21514 A 19981013  
 PRAI US 1997-08/949, 367 19971014  
 ICM C09J007-02  
 ICS B32B027-08

L10 ANSWER 5 OF 6 USPATFULL on STN

Full  Citing  References  
 Text

AN 1999:124593 USPATFULL  
 TI Protective films and coatings  
 IN Barrera, Denise A., Oakdale, MN, United States  
 PA Minnesota Mining and Manufacturing Company, St. Paul, MN, United States  
 (U.S. corporation)  
 PI US 5965256 19991012  
 AI US 1997-949367 19971014 (8)  
 DT Utility  
 FS Granted  
 LN.CNT 1325  
 INCL INCLM: 428/354.000  
 INCLS: 428/201.000; 428/203.000; 428/204.000; 428/421.000; 428/422.000;  
 428/423.100; 428/424.200; 428/424.400; 428/522.000; 427/487.000;  
 427/508.000; 427/521.000; 427/522.000; 427/407.100; 526/245.000;

NCL      NCLM:  525/123.000; 525/126.000  
          NCLS:  428/354.000  
          NCLS:  427/407.100; 427/487.000; 427/508.000; 427/521.000; 427/522.000;  
              428/201.000; 428/203.000; 428/204.000; 428/421.000; 428/422.000;  
              428/423.100; 428/424.200; 428/424.400; 428/522.000; 525/123.000;  
              525/126.000; 526/245.000  
  
IC      [6]  
        ICM: B32B027-08  
        ICS: B32B027-16; B32B027-30; B32B027-40  
  
EXF      428/201; 428/202; 428/203; 428/353; 428/354; 428/421; 428/422;  
              428/423.1; 428/424.2; 428/424.4; 428/522; 526/245; 525/123; 525/126;  
              427/487; 427/508; 427/521; 427/407.1  
  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

L10 ANSWER 6 OF 6 USPATFULL on STN

[Full Text](#)   [Citing References](#)

AN 93:3477 USPATFULL  
TI Method of making photographic element having epoxy overlayer  
IN Kobayashi, Tohru, Hino, Japan  
Nishi, Yasuo, Hino, Japan  
Nakano, Nakaya, Hino, Japan  
Ohkawa, Kazuo, Tokyo, Japan  
Tachikawa, Hiroyuki, Tokyo, Japan  
PA Konica Corporation, Tokyo, Japan (non-U.S. corporation)  
PI Asahi Denka Kogyo K.K., Tokyo, Japan (non-U.S. corporation)  
US 5178996 19930112  
AI US 1992-897578 19920611 (7)  
RLI Continuation of Ser. No. US 1991-670371, filed on 14 Mar 1991, now abandoned which is a continuation of Ser. No. US 1989-458303, filed on 28 Dec 1989, now abandoned  
PRAI JP 1988-335608 19881229  
DT Utility  
FS Granted  
LN.CNT 986  
INCL INCLM: 430/532.000  
INCLS: 427/331.000; 430/271.000; 430/273.000; 430/523.000; 430/531.000;  
        430/961.000  
NCL NCLM: 430/532.000  
NCLS: 427/331.000; 430/271.100; 430/273.100; 430/523.000; 430/531.000;  
        430/961.000  
IC [5]  
      ICM: G03C001-76  
EXF 430/271; 430/273; 430/523; 430/531; 430/532; 430/961; 427/331  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

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